

CONTENTS

| | Page |
|--|------|
| 1. Ceramic Films and coatings – An Overview | 1 |
| 1 Introduction | 1 |
| 2 Areas of Application of Ceramic Films and Coatings | 2 |
| 3 Processing of Ceramic Films and Coatings | 3 |
| 4 Characterization of Ceramic Films and Coatings | 6 |
| 5 Trends in Ceramic Films and Coatings | 10 |
| 6 Concept of the Present Book | 15 |
| Appendix A List of Abbreviations and Acronyms | 16 |
| References | 18 |
| 2. CVD Coated Cutting Tools | 22 |
| 1 Introduction | 22 |
| 2 TiC Coatings | 23 |
| 3 TiN Coatings | 27 |
| 4 Al ₂ O ₃ Coatings | 28 |
| 5 Multi – Layer Coatings | 29 |
| 6 Coating Thickness Optimization | 33 |
| 7 Other Coatings | 36 |
| References | 41 |
| 3. Wear Resistant thin Films by Ion Implantation | 42 |
| 1 Introduction | 42 |
| 2 Wear processes in Ceramics | 44 |
| 3 Fundamental Processes in Ion-Solid Interactions | 49 |
| 4 Ion Implantation of Ceramics | 53 |
| 5 Ion Beam Mixing | 62 |
| 6 Ion Beam Assisted Deposition | 65 |
| 7 Summary | 70 |
| References | 71 |
| 4. Corrosion Resistant Thick Films by Enamelling | 77 |
| 1 Introduction to Porcelain Enamels | 77 |
| 2 Porcelain Enamelling Principles and Theories | 80 |
| 3 Applications and Improvement Methods for Protective Porcelain Enamel Coating | 105 |
| 4 Summary | 115 |
| References | 119 |
| 5. Plasma Sprayed Ceramic Coatings | 131 |
| 1 Introduction | 131 |
| 2 Plasma Spraying | 132 |
| 3 Alumina-Based Ceramics | 139 |
| 4 Thermal Barrier Coatings | 143 |
| 5 Plasma Sprayed high T _c Superconductors | 160 |
| 6 Test Methodologies | 175 |
| References | 180 |
| 6. Optical Thin Films | 189 |
| 1 Introduction | 189 |
| 2 Optical Thin Film Design | 190 |
| 3 Thin Film Materials | 195 |

| | | |
|-----|---|-----|
| 4 | Deposition Process | 197 |
| 5 | Film Properties | 201 |
| 6 | Attempts at Improved properties | 208 |
| 7 | Conclusion | 217 |
| | References | 217 |
| 7. | Sol – Gel Derived Ceramic Coatings | 224 |
| 1 | Introduction | 224 |
| 2 | Sol-Gel Processing | 225 |
| 3 | Coatings via Sol-Gel Processing | 231 |
| 4 | Applications | 237 |
| 5 | Outstanding problems | 260 |
| 6 | Future Directions | 269 |
| | References | 271 |
| 8. | Electronic Thick Film Technology | 284 |
| 1 | Introduction | 284 |
| 2 | Materials | 289 |
| 3 | Resistors | 295 |
| 4 | Dielectrics | 296 |
| 5 | Capacitors | 297 |
| 6 | Future Directions | 297 |
| | References | 300 |
| 9. | Electronic Films From Metallo-Organic Precursors | 303 |
| 1 | Introduction | 303 |
| 2 | Metallo – Organic Systems | 307 |
| 3 | Processing | 321 |
| 4 | Examples of MOD Films | 336 |
| 5 | Summary | 341 |
| | References | 343 |
| 10. | Chemical Characterization Techniques for Thin Films | 348 |
| 1 | Introduction | 348 |
| 2 | X-Ray Photoelectron Spectroscopy (XPS) | 350 |
| 3 | Auger Electron Spectroscopy (AES) | 363 |
| 4 | Backscattering Spectrometry (RBS and ISS) | 369 |
| 5 | Secondary Ion Mass Spectroscopy (SIMS) | 374 |
| 6 | Summary | 379 |
| | References | 380 |
| 11. | High T_c Superconducting Thin Films | 382 |
| 1 | Introduction | 382 |
| 2 | Vacuum Deposition | 387 |
| 3 | Non-Vacuum Deposition | 395 |
| 4 | Comparison of the Thin Film Techniques | 396 |
| 5 | Other high T_c Superconductors | 399 |
| 6 | Substrate | 399 |
| 7 | Applications | 402 |
| 8 | Conclusion | 403 |
| | References | 404 |
| 12. | Chemical Vapor Deposited Diamond | 413 |
| 1 | Introduction | 413 |
| 2 | Historical Background | 414 |
| 3 | Methods of Deposition | 415 |
| 4 | Growth and Quality of CVD Diamond | 419 |
| 5 | Thermal Properties of CVD Diamond | 427 |
| 6 | Optical Properties | 429 |
| 7 | Mechanical Properties | 432 |

| | | |
|---|-----------------------|-----|
| 8 | Polishing CVD Diamond | 434 |
| 9 | Conclusion | 436 |
| | References | 437 |
| | Index | 442 |